PATENT NUMBER

ISSUE CLASSIFICATION

Class	Subclass

U.S. **UTILITY** Patent Application

nT	O.I.P.E.		PATENT DATE
SCANNED NS 2 Q.A.			

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/994808	F	430	270.1	1752	LEE, S.J.

APPLICANTS

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TITLE

Amine compounds, resist compositions and patterning process

PTO-2040
12/99

ISSUING CLASSIFICATION

ORIGINAL			CROSS REFERENCE(S)						
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						

INTERNATIONAL CLASSIFICATION

☐ Continued on Issue Slip Inside File Jacket

TERMINAL DISCLAIMER ☑	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.

☐ The term of this patent subsequent to _____ (date) has been disclaimed.

(Assistant Examiner)   (Date)

NOTICE OF ALLOWANCE MAILED

☐ The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____

ISSUE FEE

Amount Due	Date Paid

(Primary Examiner)   (Date)

☑ The terminal ____ months of this patent have been disclaimed.

ISSUE BATCH NUMBER

(Legal Instruments Examiner)   (Date)

Form PTO-436A
(Rev. 6/99)

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(FACE)